

FINALIZED DESIGN OF THE PULSED MAGNETS AND THEIR PS FOR SESAME RING INJECTION

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Abstract

The design of the SESAME[†] storage ring injection pulsed magnet systems have been improved in order to take benefit of the most recent realizations in synchrotrons. These pulsed systems are optimised for the injection into the 2.5GeV storage ring of the 800 MeV electrons beam prepared by the Booster. The septum magnet is based on a direct driven septum technology, out of vacuum, with a thin vacuum chamber of rectangular cross section permitting to get a good field transverse homogeneity. The four kicker magnets will be of the window frame geometry, around a racetrack alumina vacuum chamber, integrating a forced air cooling in order to avoid significant thermal heating due to the stored beam. These magnets can be opened for backup and will be completely CEM shielded. Their pulsed power supplies will be built based on solid-state HV switches, even for short half-sine pulses generation.

INTRODUCTION

The injection process from the 800MeV booster to the 2.5GeV storage ring unlike the original Bessy-I, takes place in the horizontal plane[1]. The microtron and booster are installed inside the main ring, so the injected beam comes from the inner side of the straight section. The injection scheme (four kickers closed orbit bump) foresees the septum with two kickers in a long straight section, while the other two kickers will be positioned in the two adjacent short straights. The design of kicker magnets and pulsed power supplies are identical and close to the SOLEIL design.

SEPTUM MAGNET

Fast deflection of the beam from transferline to the ring is accomplished with a thick septum followed by a thin septum just after 1m. The thin septum magnet is a direct driven and out of vacuum with a rectangular vacuum chamber for the incoming beam. The EM transient analysis shows a better field homogeneity in the good field region for a rectangular vacuum chamber in comparison with the round pipe chamber. The magnet yoke is laminated steel in order to avoid the effects of eddy current losses during the 250 μ s pulse. The injection point is defined to be at the downstream end of the thin

septum, where the injected beam is parallel and 32mm from the nominal orbit. The distance between the injected beam and the bumped beam is 12 mm, and the effective septum thickness is 3mm. The thin coil thickness is 2.5mm at the upstream and it smoothly decreases to 1mm at the septum downstream end. Static electromagnetic analysis is performed by the codes OPERA and POISSON, giving similar field homogeneity in the good - field region of septum chamber $\Delta B/B$ better than 1.5×10^{-3} . Transient analysis is performed by OPERA and the results show the field homogeneity in the good field region better than 0.37%. The field attenuation of 250 μ s field pulse, due to the 0.5mm thick vacuum chamber is at most 4%. The transient analysis shows the stray field without any magnetic shielding has a RMS value of 1.7% of the maximum peak field which is equivalent to 0.02 T.

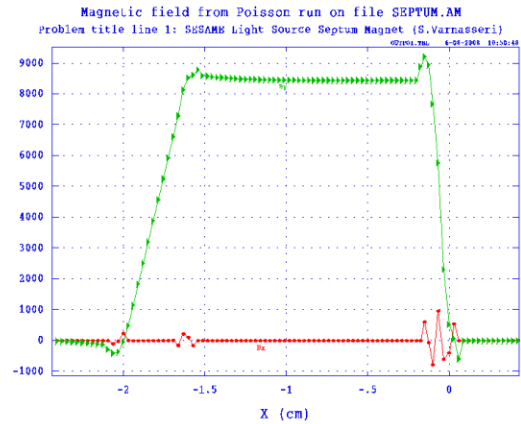


Figure 1: Static analysis of the septum fields on axis $y=0$, B_x (red) and B_y (green).

Table 1: SESAME injection septum specifications.

Deflection angle(degree)	9
Field Strength(T) @ 800MeV	0.84
Stray Fields (max.)	0.017
Magnetic Length (m)	0.5
Septum Thickness(mm)	2.5
Magnet Aperture(mm ²)	11 \times 30
Pulse Duration (us)	250
Conductor Resistance(m Ω)	0.98
Inductance(μ H)	1.3
Peak Current(A)	7360
Peak Power(kW)	56
Average Power(W)	7
PS Voltage(V)	350

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[†] Synchrotron-light for Experimental Science and Applications in the Middle East is an independent intergovernmental organization developed under the auspices of UNESCO. It involves at present the following member states: Bahrain, Cyprus, Egypt, Islamic Republic of Iran, Israel, Jordan, Pakistan, Palestinian Authority and Turkey.

KICKER MAGNETS

Four kicker magnets are required for injection process into the SESAME storage ring. The magnets have identical specifications and are expected to produce identical magnetic fields. Therefore they have the same electrical, mechanical and magnetic design. Each kicker magnet is to produce a maximum field of 0.031T in order to make a nominal transverse horizontal kick of 3.5 mrad. Since the design of the pulsed power supply and the connection cable length is an integrated part of the magnets specifications, so the maximum length of the cables is taken into account. The current pulse shape will be half sine wave with repetition rate of 1 Hz. Fig.2 shows the layout of injection kickers in the storage ring for a 20 mm horizontal bump.

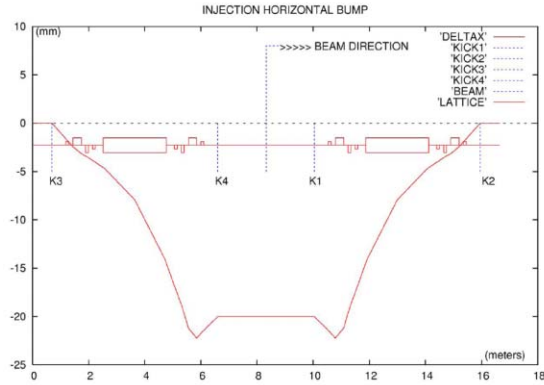


Figure 2: SESAME injection horizontal bump scheme.

The kickers strengths for a 20 mm bump are given in table.2 for the linear (without sextupole) and nonlinear (with sextupole) cases. The maximum kick required for kicker K3 is 3.46 mrad which is the base for the design of identical kicker with strength of 3.5 mrad.

Table 2: Injection kickers strength for 20 mm bump.

Strength (mrad)	K1	K2	K3	K4
Without sextupole	-3.16	-3.39	-3.39	-3.16
With sextupole	-3.09	-3.46	-3.46	-3.09

Kicker magnets are one turn coil with ferrite yoke, with a window frame shape adapted from the SOLEIL design[2]. Ferrite yokes are made of 8C11 C-shape pieces, which constitute two half symmetric magnet yokes, located each one on a plate which can be opened. To get a good matching of all the kicker magnets, it is necessary to have specific attention on the transverse dimensions and tolerances, the positioning of the ferrite cores and the coil parts (insulated and maintained by dielectric machined C parts). With these arrangements the control of parameters of the four kickers, like the transverse field homogeneity and leakage inductance, will be achievable. The design of the magnet also includes a free gap (2 mm) around the alumina needed for the air cooling. Such a cooling needs a regular free gap, but not a too wide gap in order to distribute the air around the ceramic in turbulent flow. It is foreseen not to use forced air due to the low temperature raise during the operation of kickers (maximum 48°C), but there is the possibility to

include an air forced cooling, in the vertical plane, to avoid any overheating of the ceramic due to the beam image current. The vacuum chamber is made of ceramic with 2 μ m Ti coating. The optimization of the coating thickness has been carried out in order to be thick enough for the thermal issues and thin enough not to attenuate and ill-shape too much the magnetic field [1,3].

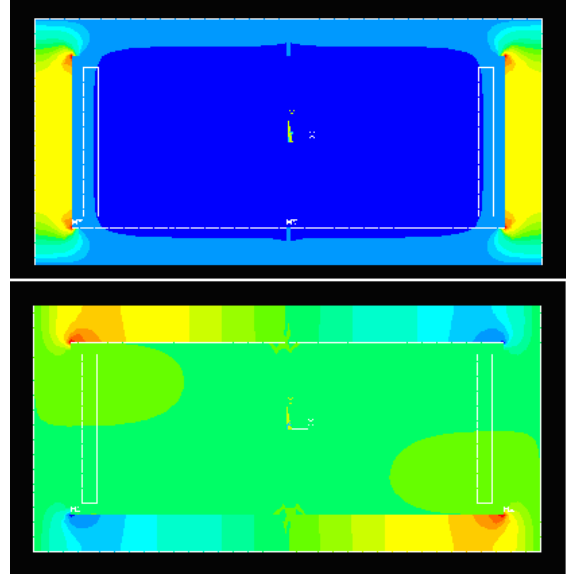


Figure 3: Magnetic field density, Bx(lower) and By(upper) of the kicker magnet.

Study on using short pulse width also has been carried out with close collaboration with SOLEIL, due to the eddy currents attenuation on the penetrating field from the vacuum chamber. The intention was to use an optimised pulse period based on optics requirements and experience of solid state high voltage technology already available at SOLEIL. Fig.4 shows the attenuation of the magnetic field for various pulse durations.

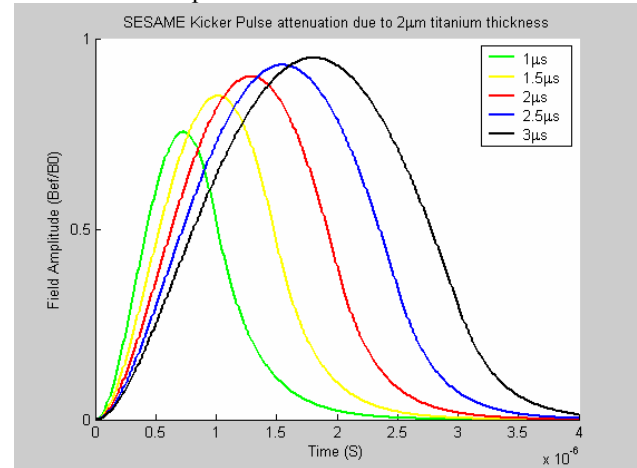


Figure 4: Field attenuation for various pulse durations.

The whole magnet will be enclosed in an electromagnetic shield, in order to avoid any EM perturbations to the side-equipments. The magnet design is also considered taking into account the electric design and SPICE simulations of the whole system, including pulser, coaxial transmission

